

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2001-164354

(43)Date of publication of application : 19.06.2001

(51)Int.Cl.

C23C 4/10

C23C 14/00

C23C 16/06

// H01L 21/3065

H01L 21/31

(21)Application number : 11-351546

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(22)Date of filing :

10.12.1999

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(54) MEMBER INSIDE PLASMA TREATMENT CHAMBER, AND MANUFACTURING METHOD THEREFOR

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a member inside a plasma treatment chamber, excellent in plasma erosion resistance, and to provide an advantageous manufacturing method therefor.

SOLUTION: The surface of a base material is coated with a multilayered combined layer consisting of a metal film formed as an undercoat, an Al₂O₃ film formed as an intermediate layer on the undercoat, and a Y₂O₃ sprayed deposit formed as a topcoat on the intermediate layer.

CLAIMS

[Claim(s)]

[Claim 1] Interior material of a plasma treatment container characterized by covering the front face of a base material with 2OY3 sprayed coating.

[Claim 2] Interior material of a plasma treatment container according to claim 1 characterized by having a metallic film as an under coat under the Y₂O₃ sprayed coating formed as topcoat.

[Claim 3] Interior material of a plasma treatment container according to claim 2 characterized by having an interlayer between the metallic film formed as an under coat, and 2OY3 sprayed coating formed as topcoat.

[Claim 4] The gap or one or more sorts of metals which be chosen from nickel and its